淡江大學 98 學年度轉學生招生考試試題

系別:電機工程學系三年級

科目:電子。學

准帶項目請打「V」

V 計算機

本試題共 5 大題,

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- 1. Briefly explain the meaning of the following terminology.
- (a) (5%) Channel-length modulation.
- (b) (5%) Body effect.
- (c) (5%) Short-circuit transconductance.
- (d) (5%) Zener breakdown.
- 2. A uniform n-type piece of silicon with a length of L m and a cross section area of A m² sustains a voltage difference of V volt. The mobilities of electron and hole are μ_n m²/(V· s) and μ_p m²/(V· s), respectively.
- (a) (10%) Compute the velocities of electrons and holes in this material.
- (b) (10%) If the doping level is N_D m⁻³ and $N_D \gg n_i$ where n_i is the carrier density in intrinsic silicon. Find the total current density flowing through the device.
- (c) (5%) Is it possible the drift current of hole is equal to the drift current of electron in an n-type silicon?
- 3. (15%) Consider the circuit shown in Figure I, where $I_S=6\times 10^{-16}$ A, $I_1=2$ mA, $V_T=26$ mV, and $V_A=\infty$. Determine the value of V_B .

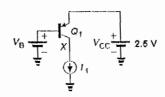


Figure 1

4. (25%) Consider the circuit shown in Figure 2, determine the voltage gain and input/output impedances under the assumption $V_A = \infty$ and C_B is very large.

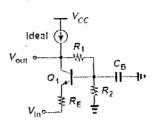


Figure 2

5. (15%) Consider the circuit shown in Figure 3, the parameters are $\mu_n C_{ox} = 200 \ \mu\text{A/V}^2$, W/L = 20/0.18, $\lambda = 0$, and $V_{TB} = 0.4 \ \text{V}$. Determine the value of V_B such that M_1 operates at the edge of saturation region.

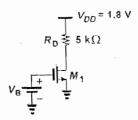


Figure 3